

Sulfur in Organic and Inorganic Chemistry; ed. by A. Senning, Dekker, New York, 1971, Vol. 1, xiv+380 pages. £15.70.

This is the first in a multi-volume series which is meant to present "an integrated treatment of sulfur chemistry across the traditional lines of inorganic, organic, physical-chemical and biochemical aspects of chemistry". A review in this journal is justified only because of a chapter on the Sulfur-Silicon Bond by A. Haas, which includes discussion of organosilicon sulphides, but the chapter is so brief (8 pages, of which only 4 are text, and with only 28 references) as to be of very limited value. It is said to be "mostly devoted to the theoretical aspects of silicon-sulfur bonding", but there are only a few, and very vague, lines on this topic.

Other chapters deal, respectively, with S-N, S-P, S-O, S-S, S-F, S-Cl, S-Br, and S-I bonds.

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ERRATUM

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Page C57, line 16 should read:

vals ($\pm 40 \text{ cm}^{-1}$): SiCl_4^+ , 340; MeSiCl_3^+ , 370; $\text{Me}_2\text{SiCl}_2^+$, 300; and $(\text{Me}_2\text{N})\text{SiCl}_3^+$, 315 cm^{-1}